

TITANIUM

Sputtering Target

NS6130-10-1052

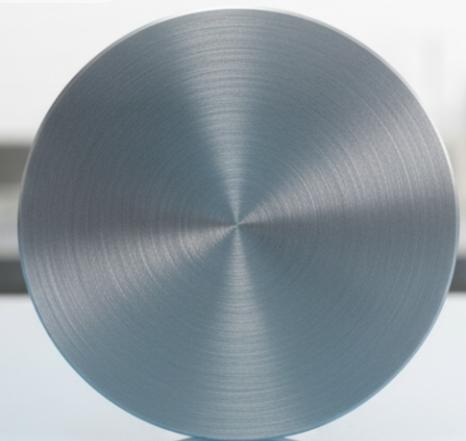
Quick Facts

Product	:	Titanium Sputtering Target
Stock No	:	NS6130-10-1052
CAS	:	7440-32-6
Purity	:	99.99%
Molecular Formula	:	Ti

Technical Specification

Diameter	Thickness	Molecular Weight
50.8 mm ± 1mm	3 mm ± 0.5mm	47.86g/mol

Titanium sputtering targets are valuable materials for the production of thin films with specific properties for various applications in the semiconductor and electronics industries. The unique combination of properties, including corrosion resistance, strength-to-weight ratio, and biocompatibility, make titanium a versatile material for use in a range of applications. Used in the production of biomedical implants, such as orthopedic implants and dental implants, as well as in the production of other electronic components, such as thin-film transistors and optical coatings.



* This image is for graphic purposes only and does not represent the actual product.

